



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

JOYCE S. OEY HEWETT
ALEXANDER J. PASADYN

Serial No.: ⁰⁹10/909,112

Filed: July 19, 2001

For: USE OF SLURRY WASTE
COMPOSITION TO DETERMINE THE
AMOUNT OF METAL REMOVED
DURING CHEMICAL MECHANICAL
POLISHING, AND SYSTEM FOR
ACCOMPLISHING SAME

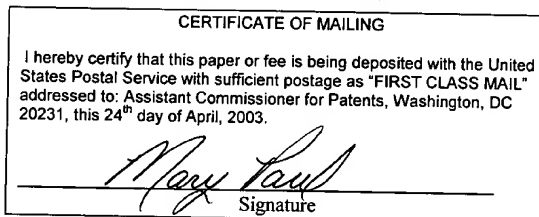
§
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§ Examiner: Lynette T. Umez Eronini
§
§ Group Art Unit: 1765
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§ Att'y Docket: 2000.089100/TT4642
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**RESPONSE TO RESTRICTION
REQUIREMENT DATED APRIL 14, 2003**

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Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:



This paper is submitted in response to the Restriction Requirement dated April 14, 2003, for which the one-month date for response is May 14, 2003.

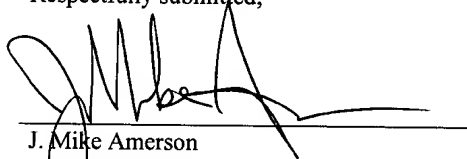
In response to the restriction requirement which the Examiner imposed, Applicants elect, with traverse, to prosecute claims 1-34, *i.e.*, the Group I claims.

It is believed that no fee is due; however, should any fees under 37 C.F.R. §§ 1.16 to 1.21 be required for any reason relating to this document, the Assistant Commissioner is authorized to deduct said fees from Advanced Micro Devices, Inc. Deposit Account No. 01-0365/TT4642. In the event the monies in that account are insufficient, the Assistant Commissioner is authorized to

withdraw funds from Williams, Morgan & Amerson, P.C. Deposit Account No.
50-0786/2000.089100.

The Examiner is invited to contact the undersigned attorney at (713) 934-4055 with any
questions, comments or suggestions relating to the referenced patent application.

Respectfully submitted,



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Date: April 24, 2003



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PATENT TRADEMARK OFFICE

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